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02451-1449 (US). **BENEDICT, James, E.**; 870 Winter Street, Waltham, MA 02451-1449 (US).

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(74) **Agent: NOE, Keith, F.** et al.; Lando & Anastasi, LLP, 60 State Street, 23rd Floor, Boston, MA 02109 (US).

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(71) **Applicant: RAYTHEON COMPANY** [US/US]; 870 Winter Street, Waltham, MA 02451-1449 (US).

(72) **Inventors: HAVEN, John, P.**; 870 Winter Street, Waltham, MA 02451-1449 (US). **SIKINA, Thomas, V.**; 870 Winter Street, Waltham, MA 02451-1449 (US). **ADAMS, Peter, J.**; 870 Winter Street, Waltham, MA

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(54) **Title:** ADDITIVE MANUFACTURING TECHNOLOGY (AMT) LOW PROFILE RADIATOR

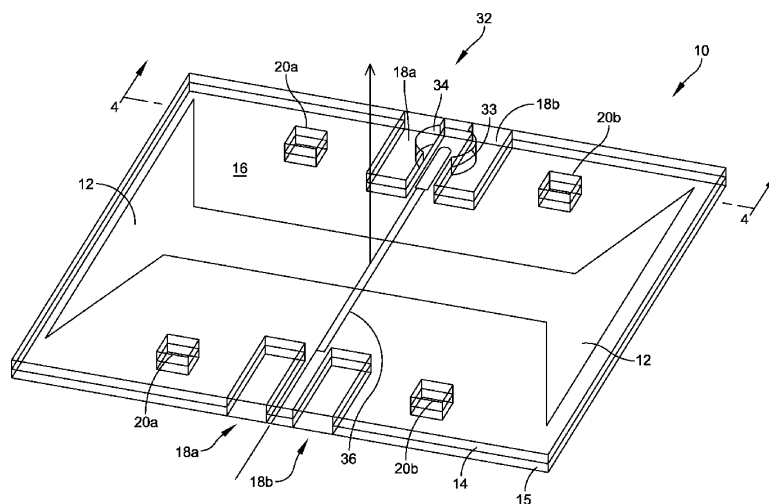


FIG. 3

(57) **Abstract:** Described herein is a low profile radiator (LPR) manufactured using additive manufacturing technology (AMT). Such an AMT radiator is suitable for use in an array antenna which may be fabricated using AMT manufacturing processes.

[Continued on next page]

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